## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

| Priority Application Serial No  |        |       | 10/071,425              |     |     |  |
|---------------------------------|--------|-------|-------------------------|-----|-----|--|
| Priority Filing Date            |        |       |                         |     |     |  |
| Inventor                        |        |       | Terry L. Gilton et al.  |     |     |  |
| Assignee                        |        |       | Micron Technology, Inc. |     |     |  |
| Priority Group Art Unit         |        |       | 2813                    |     |     |  |
| Priority Examiner               |        |       | Thanhha S. Pham         |     |     |  |
| Attorney's Docket No            |        |       | MI22-2440               |     |     |  |
| Customer No                     |        |       |                         | 021 | 567 |  |
| Title: Semiconductor Processing | Method | Using | <b>Photoresist</b>      | and | an  |  |
| Antireflective Coating          |        |       |                         |     |     |  |

## PRELIMINARY AMENDMENT

To: Mail Stop Patent Application

Commissioner for Patents

P. O. Box 1450

Alexandria, VA 22313-1450

**VIA EXPRESS MAIL** 

From: Mark Matkin (Tel. 509-624-4276; Fax 509-838-3424)

Wells St. John P.S.

601 West First Avenue, Suite 1300

Spokane, WA 99201-3828

Please enter the following amendments prior to examining the aboveidentified application.

## <u>AMENDMENTS</u>